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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/767,618	01/29/2004	Chen-Hsiung Cheng	9432-158DVB	5657
27572 7590 12/29/2006 HARNESS, DICKEY & PIERCE, P.L.C. P.O. BOX 828			EXAMINER	
			ABOAGYE, MICHAEL	
BLOOMFIELD HILLS, MI 48303			ART UNIT	PAPER NUMBER
		•	1725	
SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
3 MONTHS		12/29/2006	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

	Application No.	Applicant(s)			
	10/767,618	CHENG ET AL.			
Office Action Summary	Examiner	Art Unit			
	Michael Aboagye	1725			
The MAILING DATE of this communication		ith the correspondence address			
Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REI WHICHEVER IS LONGER, FROM THE MAILING  - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory peri  - Failure to reply within the set or extended period for reply will, by sta Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNION 1.1.136(a). In no event, however, may a relict will apply and will expire SIX (6) MON tutte, cause the application to become AB	CATION. reply be timely filed ITHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 06	<u> December 2006</u> .				
This action is <b>FINAL</b> . 2b) This action is non-final.					
3) Since this application is in condition for allow		•			
closed in accordance with the practice unde	er Ex parte Quayle, 1935 C.D	). 11, 453 O.G. 213.			
Disposition of Claims					
4) Claim(s) <u>11-19 and 24-28</u> is/are pending in	the application.				
4a) Of the above claim(s) is/are without					
5) Claim(s) is/are allowed.					
6) Claim(s) <u>11-19 and 24-28</u> is/are rejected.					
7) Claim(s) is/are objected to.	11 1 12 2 2 2 2 2 2 2 2 2 2 2				
8) Claim(s) are subject to restriction and	a/or election requirement.				
Application Papers					
9)☐ The specification is objected to by the Exam					
10) The drawing(s) filed on is/are: a) ☐ a					
Applicant may not request that any objection to t					
Replacement drawing sheet(s) including the corr 11) The oath or declaration is objected to by the					
ine oath or declaration is objected to by the	Examiner. Note the attached	JOINCE ACTION OF TOTAL			
Priority under 35 U.S.C. § 119					
<ul> <li>12) Acknowledgment is made of a claim for fore a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents.</li> <li>2. Certified copies of the priority documents.</li> <li>3. Copies of the certified copies of the priority.</li> </ul>	ents have been received. ents have been received in A	Application No			
application from the International Bur					
* See the attached detailed Office action for a	•	received.			
•					
Attachment(s)		•			
Notice of References Cited (PTO-892)  Notice of Draftsperson's Patent Drawing Review (PTO-948)  Information Disclosure Statement(s) (PTO/SB/08)	Paper No(	Summary (PTO-413) s)/Mail Date Informal Patent Application			
Paper No(s)/Mail Date .	· 6) 🔲 Other:	<del>:</del>			

Paper No(s)/Mail Date \_

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### **DETAILED ACTION**

## Claim Rejections - 35 USC § 112

- 1. The following is a quotation of the first paragraph of 35 U.S.C. 112:
  - The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.
- 2. Claims 24- 27 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

Claims 24-27 contain the new matter limitations "wherein a maximum tool pitch is less than fifty percent of average spot size; wherein the maximum tool pitch is no more than forty percent of average spot size; wherein the maximum tool pitch is no more than thirty percent of average spot size; wherein the maximum tool pitch is no more than twenty percent of average spot size. There is no support for these limitations in the disclosure.

# Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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- 4. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 5. Claims 11, 12, 15-19 and 28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lai (US Patent No. 6,231,566).

Lai teaches a laser ablating system "100" comprising: a laser source "10", a beam shaping optics "20", a scanner "40" made up of galvanometer scan mirrors, and a computer or tool path control module "50". Said laser ablation system operable to determine a tool path for ablating a layer of material from an exposed surface of a workpiece (cornea) with laser (see, column 4, lines 17-41); wherein the tool path describes a substantially constant arc speed (see, column 2, lines 3-35); a plurality of lasers (see, column 4, lines 8-16) controlled by said tool path control module to perform ablation of a plurality of workpieces according to the tool path, and wherein said tool path module is operable to formulate a radius and a local angular speed (see, column 4, lines 8-41, figures 1 and 3-5). Lai teaches spiral scanning operation for generating rings wherein the diameter of said rings vary from layer to layer (column 2, lines 25-35). Lai

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also teaches a computer program interfaced with the scanner such that both uniform and non-uniform scan path can be generated depending on the degree of tuning (column 3, lines 29-40; column 3, line 65-column 4, line 7; and column 5, lines 38-65). The examiner interprets this as a capability of executing a tool path with a non-uniform radius and angular progression.

Regarding claims 16-19, Lai laser ablating system is operable to ablate or remove successive layers of corneas; wherein each of the corneas is composed of substantially identical material and has substantially identical geometric characteristics and each of the multiple regions the corneas are composed of substantially identical material and has substantially identical geometric characteristics (see, column 1 lines 14-20, column 5, lines 7-33).

Regarding claim 28, Lai, teaches progressive tool path executed at constant repletion rate (column 2, lines 39-47)

It would have been obvious to one of ordinary skill in the art at the time the applicants invention was made to have used the system of Lai to generated laser tool path of non-uniformly changing radius since the system can be tuned to describe variations of scanning schemes by using the computer program interfaced with the scanner (column 3, lines 34-40 and column 4, lines 17-26).

6. Claims 13, 14 and 24-27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lai (US Patent No. 6,231,566) in view of Cutler et al. (US 5,798,927).

Lai further teaches a system operable to vary the scan speed according to the radius of the tool path (column 4, line 59- column 5, line 6); a beam shaping optical

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assembly or module operable in controlling the spot size based on the tool pitch or the pulse rate based of lasers (column 3, lines 29-50). It is noted that with such a system capability, the tool pitch or the pulse rate can be optimized to achieve variations of spot sizes. Lai does not expressly teach PZT scan mirror in his disclosed system.

However, Cutler et al. teaches a laser milling system for performing tool path operation using a piezoelectric transducer as a scanning device which is operable controls the repetition rate and the spot size and positioning by variation of the applied voltage across it (see, Cutler et al., column 10, lines 27-41, and figure 2).

It would have been obvious to one of ordinary skill in the art at the time the applicants' invention was made to have modified the system of Lai by using a PZT scanner as taught by Cutler et al., wherein doing so would have meant, substituting one form of positioning device for another in the same art which would have enabled the appropriate setting of tool pitch for a preferred spot size base on applied voltage per revolution (see, Cutler et al., column 10, lines 27-41).

### Response to Arguments

- 7. The examiner acknowledges the applicants' amendment received by USPTO on December 06, 2006. Claims 11-19 and 24-28 are currently under consideration in the application.
- 8. Applicant's arguments filed December 06, 2006 have been fully considered but they are not persuasive. With regard to applicant's argument that Lai only teaches "The diameters of the rings are uniformly increased or decreased in each layer", it is noted

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that Lai teaches spiral scanning operation generating rings with variation in the diameter of the rings from layer to layer (column 2, lines 25-35). Lai teaches a computer program interfaced with the scanner which can be tuned by the operator to execute either uniform or non-uniform diameter rings (column 3, lines 29-40; column 3, line 65-column 4, line 7; and column 5, lines 38-65). It is therefore noted that the system of Lai is capable of executing both uniform and non-uniform progressive tool path, thereby describing trajectories of changing radius during successive scan operations. Claims 11, 12, 15-19 and 28 are currently rejected under 35 U.S.C. 103(a) by Lai, claims 13, 14 and 24-27 are rejected under 35 U.S.C. 103(a) by the combination of Lai and Cutler et al. and claims 24-27 are rejected under 35 U.S.C. 112, first paragraph as having issues of new matter.

#### Conclusion

9. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

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the advisory action. In no event, however, will the statutory period for reply expire later

than SIX MONTHS from the date of this final action.

10. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Michael Aboagye whose telephone number is 571-272-

8165. The examiner can normally be reached on Mon - Fri 8:30am - 5pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Patrick Ryan can be reached on 571-272-1292. The fax phone number for

the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the

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USPTO Customer Service Representative or access to the automated information

system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Michael Aboagye Assistant Examiner Art Unit 1725

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